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ICTP Conference Graphene Week 2008

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Shot noise in ballistic and disordered graphene

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Shot noise in ballistic and disordered graphene

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Low Temperature Laboratory

***Monica Craciun, Alberto Morpurgo, Jeroen Oostinga,
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and

Asta Kärkkäinen

Nokia Research Center



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Outline

- *Introduction to shot noise*
- *Theoretical background*
- *Experimental techniques*
 - *Noise measurement techniques*
- *Experimental results*
 - *Shot noise in graphene sheets*
 - *Shot noise in graphene nanoribbons*
- *Summary*

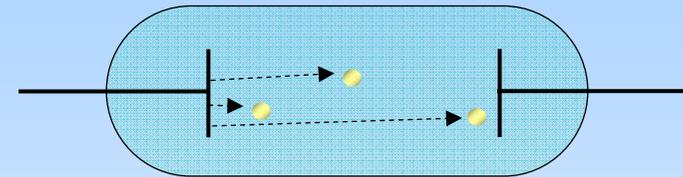


Shot noise in electronic system

Classical shot noise:
Poissonian process

$$S_P = 2q\langle I \rangle$$

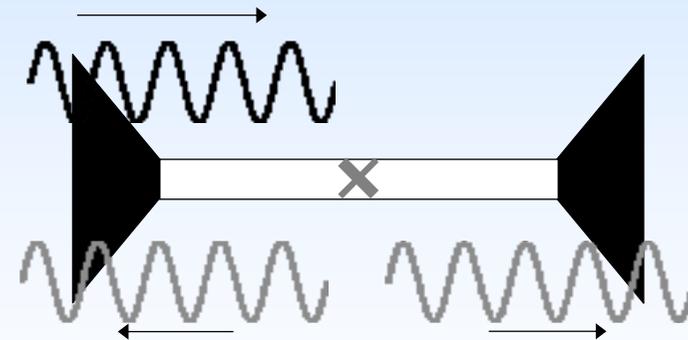
uncorrelated emission events



Schottky, (1918)

Quantum shot noise:
binominal process

$$S = \frac{q^3 |V|}{\pi \hbar} T(1-T)$$
$$= 2q\langle I \rangle(1-T)$$



Khlos (1987), Lesovik (1989)



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Fano factor

$$S = \frac{e^3 |V|}{\pi \hbar} \sum_n T_n (1 - T_n)$$

- Sum over quantum partition noise of the eigenchannels

$$S_P = 2e \langle I \rangle \quad G = \frac{e^2}{\pi \hbar} \sum_n T_n$$
$$= \frac{e^3 |V|}{\pi \hbar} \sum_n T_n$$

$$F = S / S_P = \frac{\sum_n T_n (1 - T_n)}{\sum_n T_n}$$

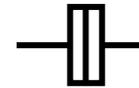
- At finite temperature:

$$S = \frac{e^2}{\pi \hbar} \left[2k_B T \sum_n T_n^2 + eV \coth\left(\frac{eV}{2k_B T}\right) \sum_n T_n (1 - T_n) \right],$$



A few examples

Tunnel junction (TJ)



$$F = 1 \quad (T \rightarrow 0)$$

2 TJs in series



$$\frac{R_1^2 + R_2^2}{(R_1 + R_2)^2}$$

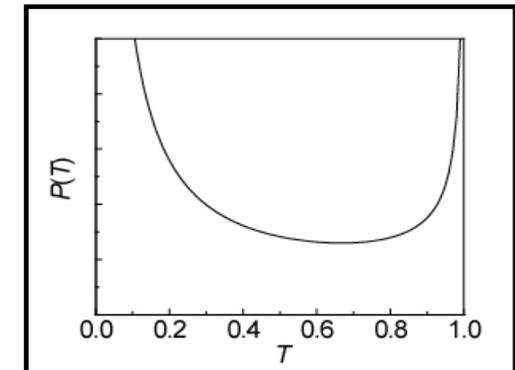
1D diffusive conductor



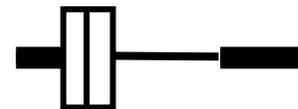
$$F = \frac{1}{3}$$

1D diffusive conductor

$$P(T) = \frac{1}{2L} \frac{1}{T\sqrt{1-T}}$$



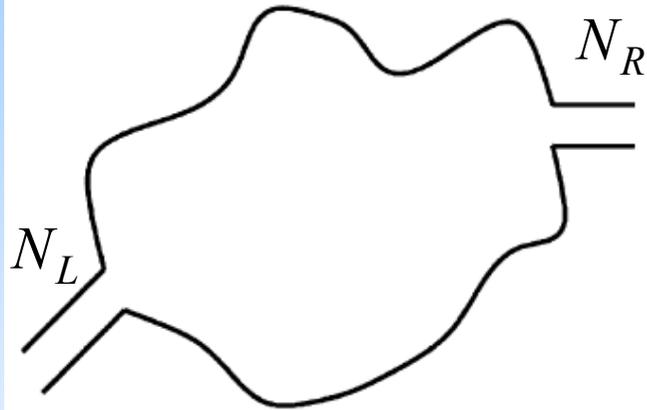
TJ plus 1D diffusive conductor



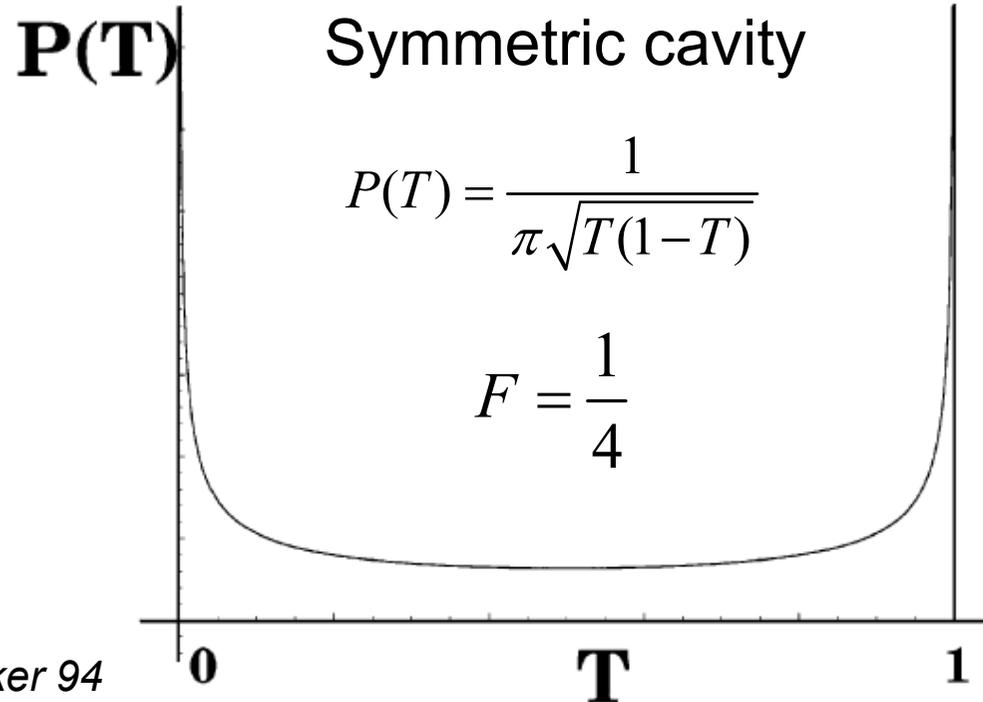
$$F = \frac{1}{3} \left[1 - \frac{3T-2}{(1+TL/l_{el})^3} \right]$$



Chaotic cavity



Baranger and Mello 94
Jalabert, Pichard, and Beenakker 94



$$F = \frac{N_L N_R}{(N_L + N_R)^2}$$

$$F = \frac{1}{4} \exp\left(-\frac{t_E}{t_D}\right)$$

Goes to zero in very asymmetric cavities

t_E - Ehrenfest time

t_D - dwell time

Agam, Aleiner, and Larkin 2000



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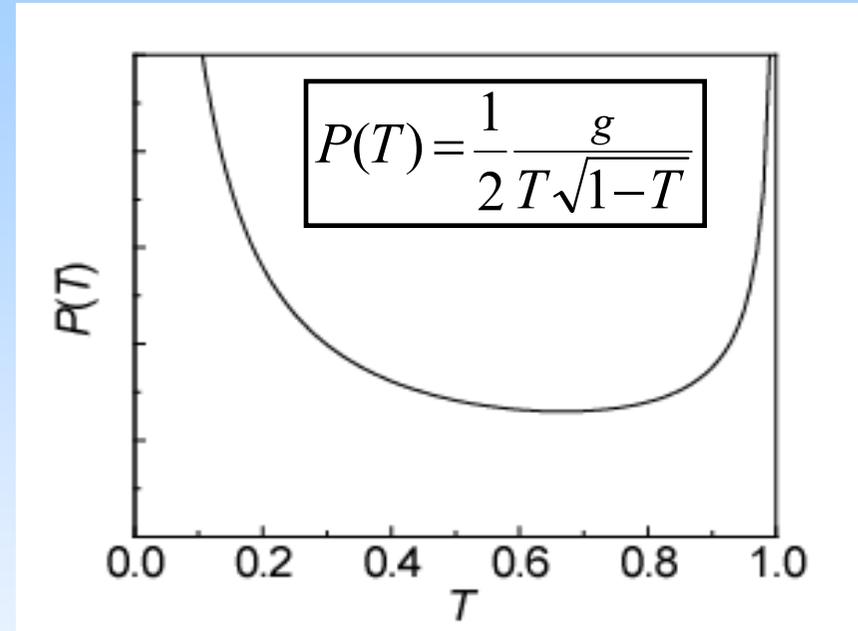
Quantum vs. classical



Distribution of eigenvalues in ballistic graphene

$$T_n = \frac{1}{\cosh^2 \left[(n + \alpha) \pi \frac{L}{W} \right]}$$

$$\frac{W}{L} \rightarrow \infty \quad F = \frac{\sum_n T_n (1 - T_n)}{\sum_n T_n} = \frac{1}{3}$$



*J. Tworzydło, B. Trauzettel, M. Titov, A. Rycerz, and C. W. Beenakker, Phys. Rev. Lett. **96**, 246802 (2006).*

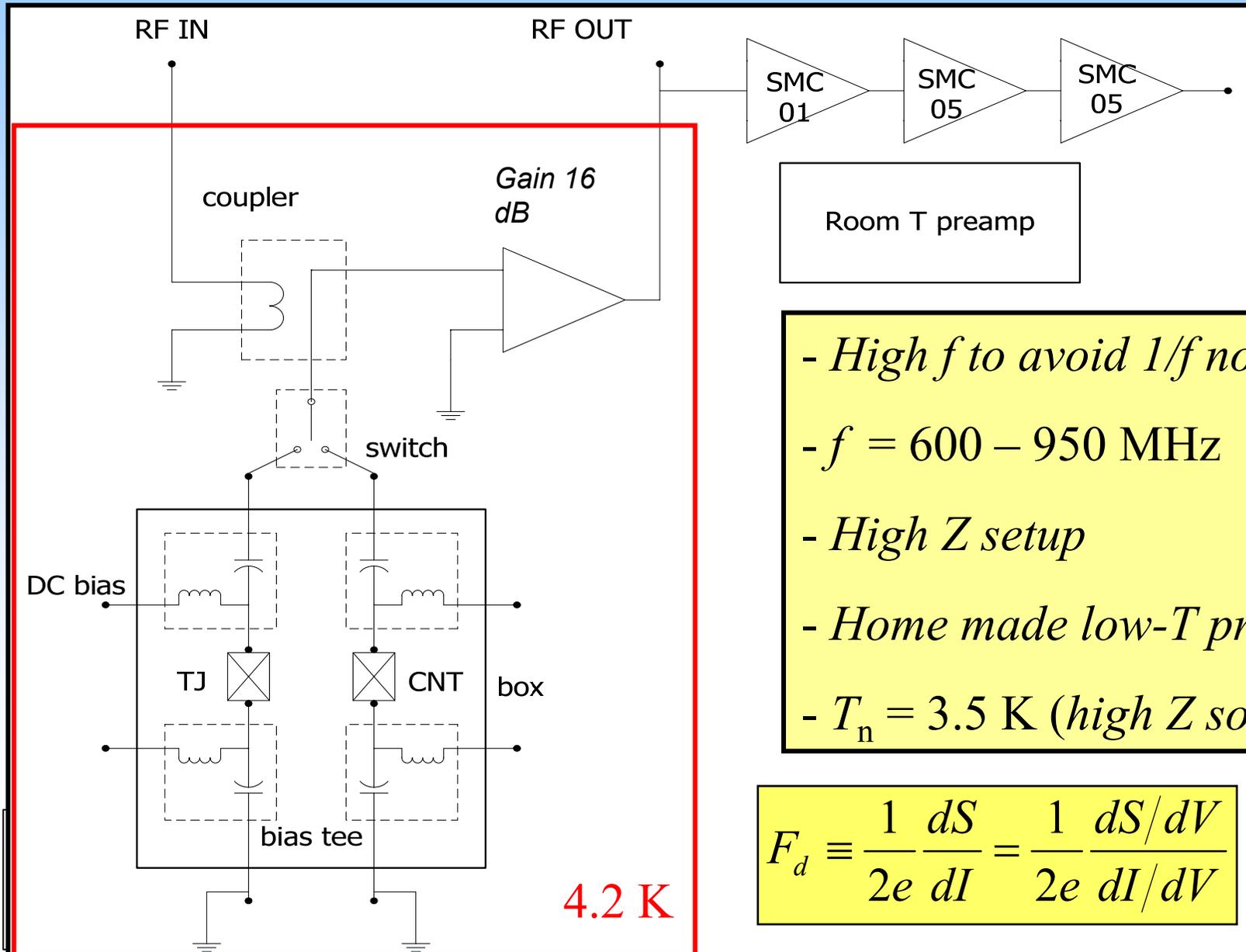
*M.I. Katsnelson, Eur. Phys. J. B **51**, 157 (2006).*



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Schematics of measurement setup

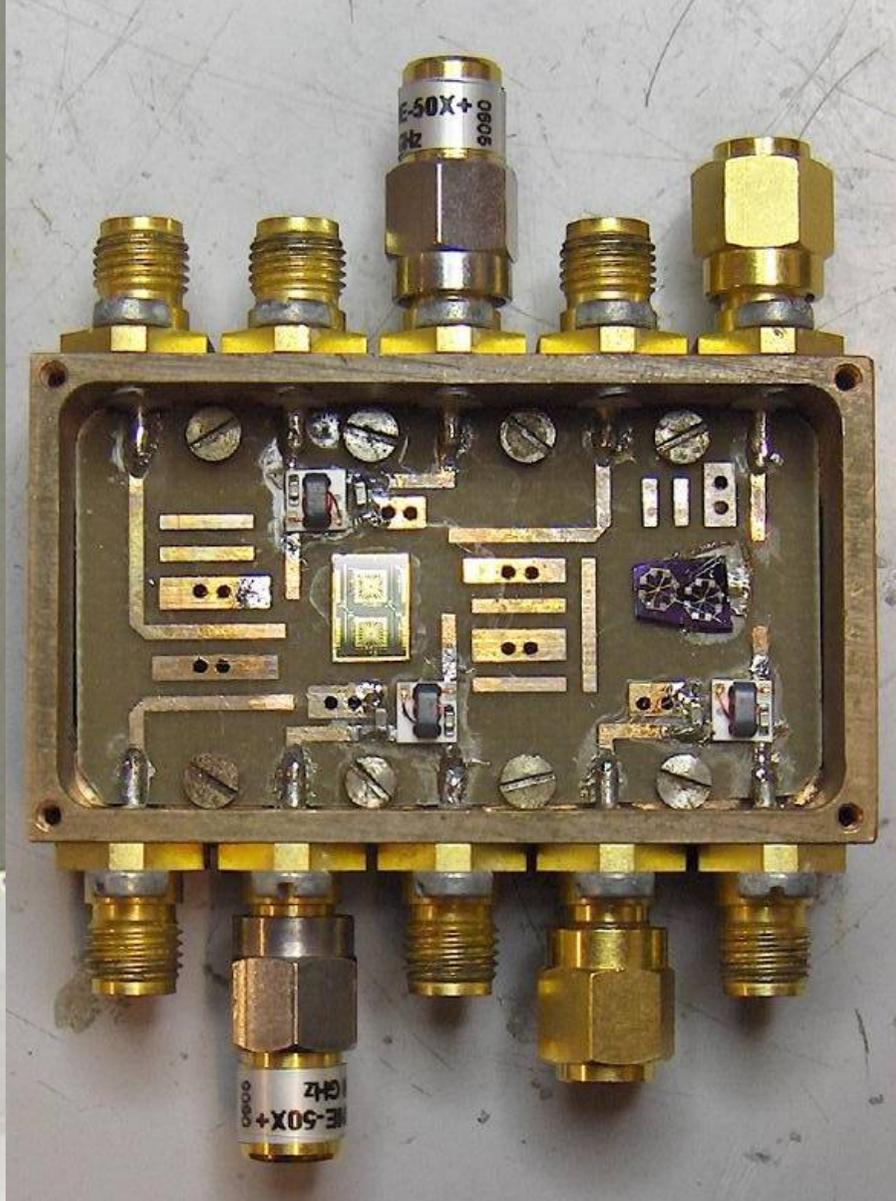
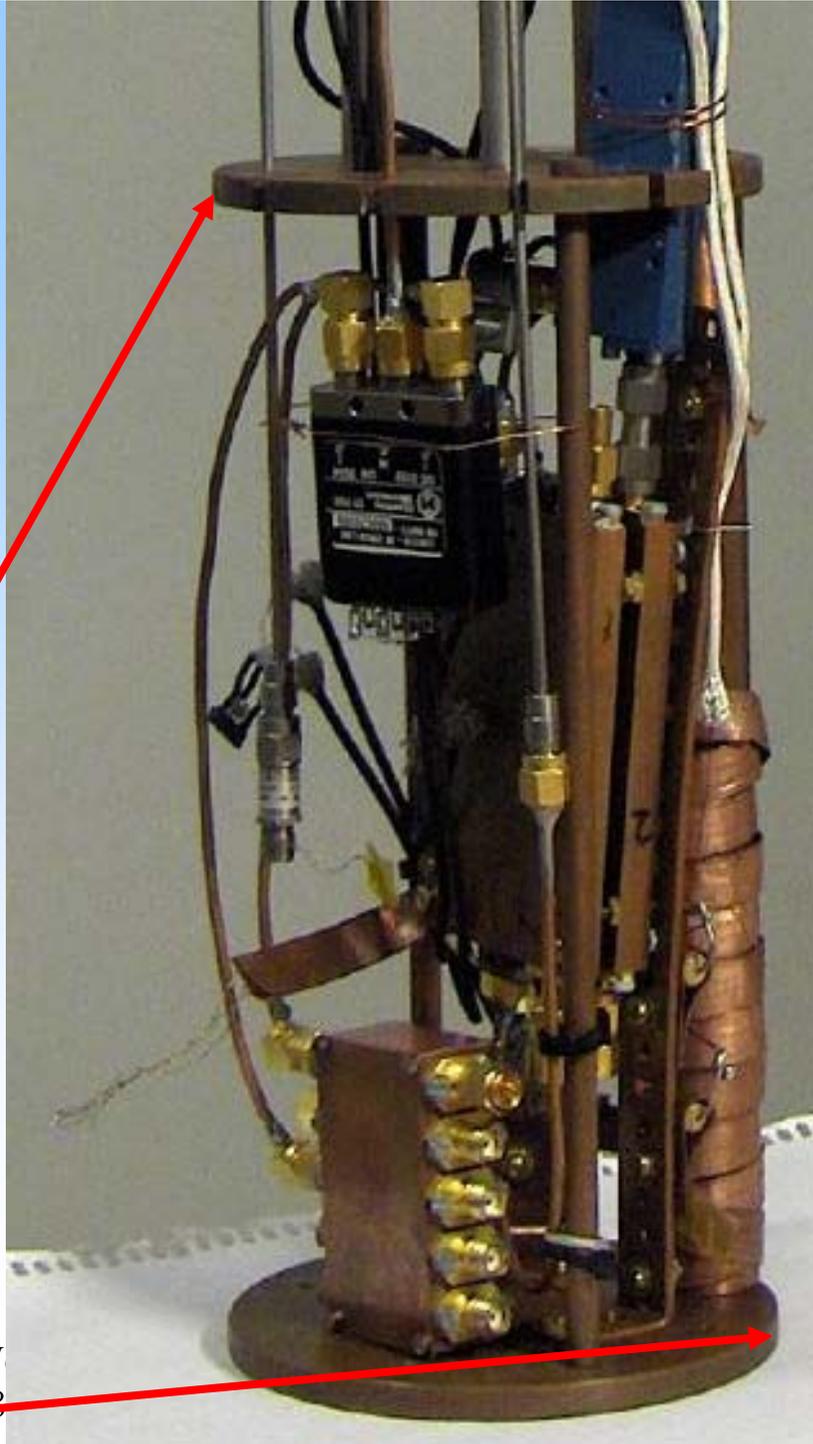
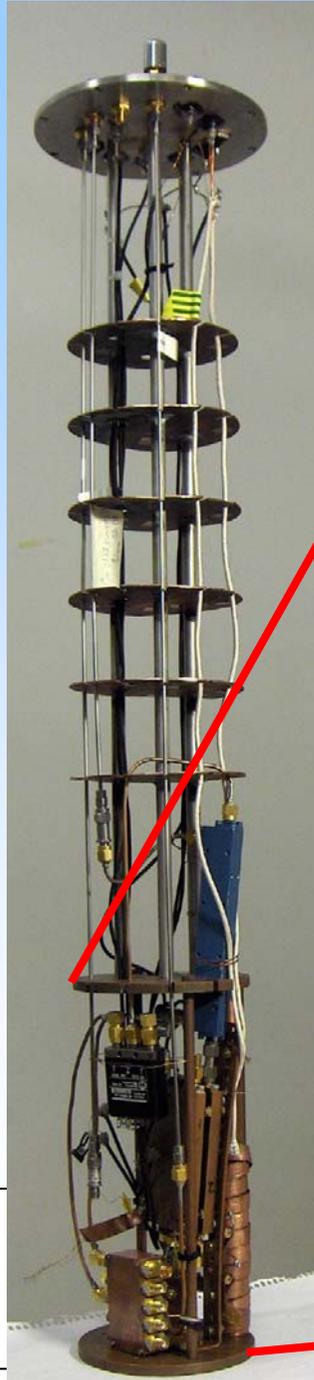


- High f to avoid $1/f$ noise
- $f = 600 - 950$ MHz
- High Z setup
- Home made low- T preamplifier
- $T_n = 3.5$ K (high Z source: 14K)

$$F_d \equiv \frac{1}{2e} \frac{dS}{dI} = \frac{1}{2e} \frac{dS/dV}{dI/dV}$$

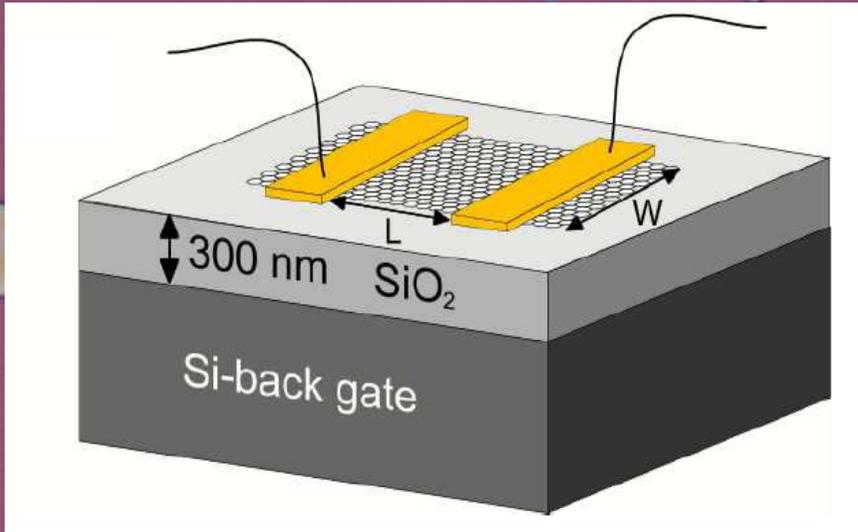
$$\tilde{F} = \frac{1}{I} \int_0^I F_d dI$$

Measurement setup



W
18

Shot noise in graphene



$W/L \sim 10$
 $L = 200 \text{ nm}$



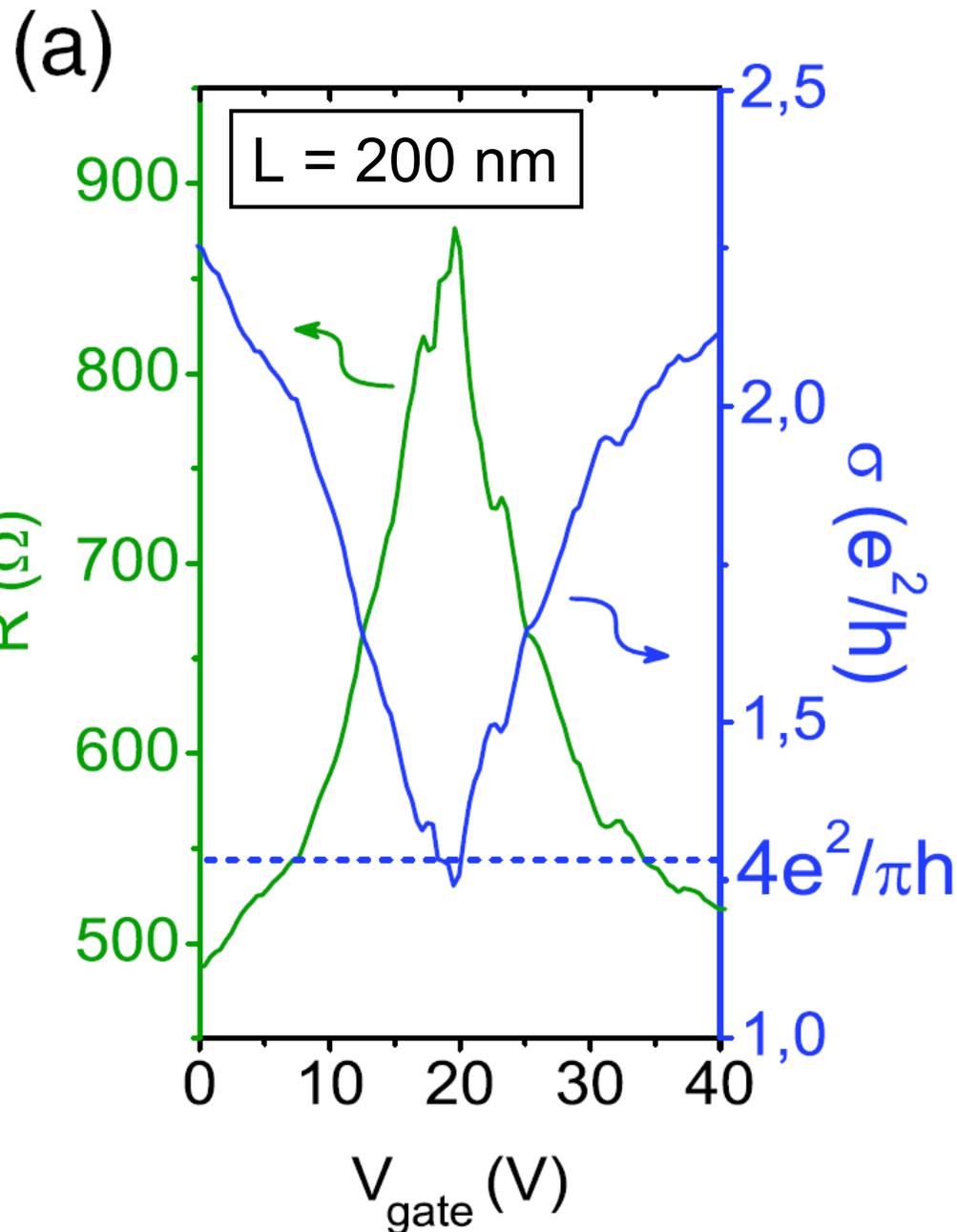
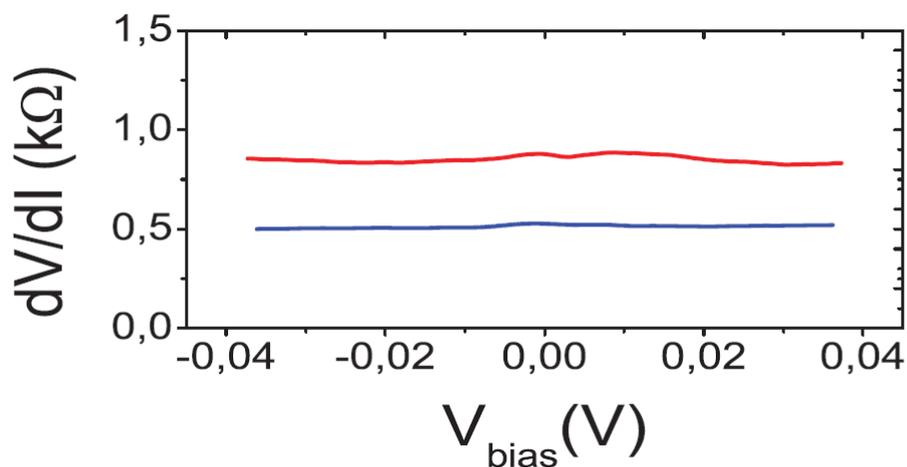
Sample with $W/L=24$

SAMPLE:

- Single layer
- $W/L = 4.8 / 0.20 \sim 24$,
- Ti/Au contacts (10/40 nm)

minimum conductivity: $\frac{4e^2}{\pi h}$

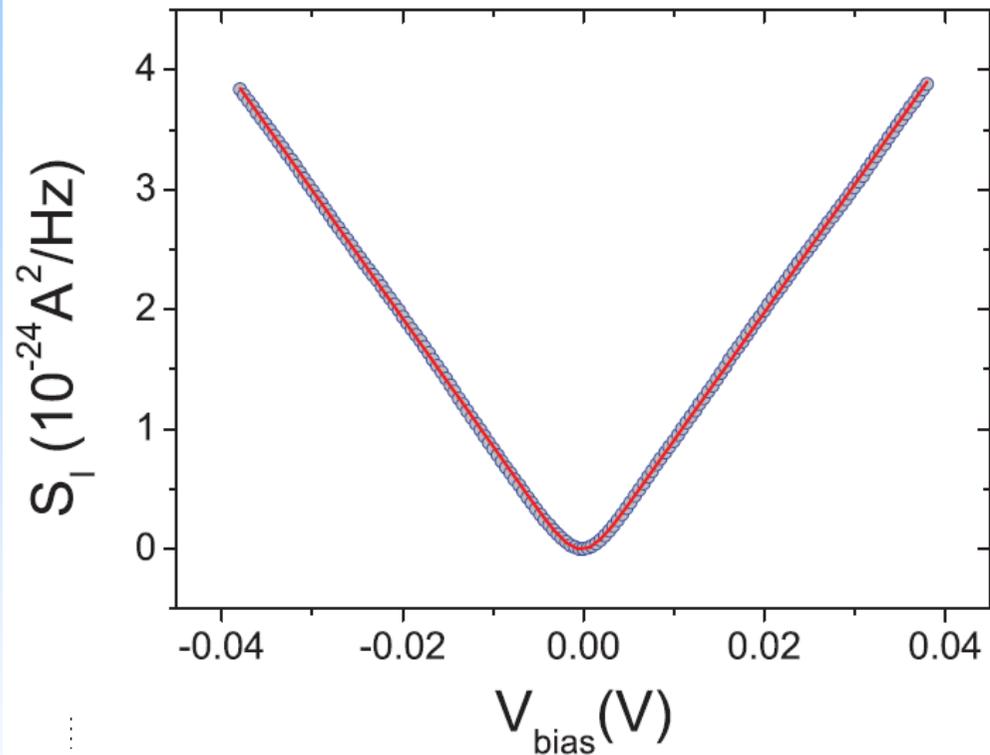
Seen also by:
F. Miao *et al.*, Science **317**, 1530 (2007).



p-doping with gate shift of 20 – 200 V
(uppermost breakthrough at 139 V)



Current noise vs. bias at Dirac point



$$S(V, T) - S(0, T)$$

$$= \frac{4k_B T}{R} F \left(\frac{eV}{2k_B T} \coth \left(\frac{eV}{2k_B T} \right) - 1 \right)$$

- T fixed, F only parameter

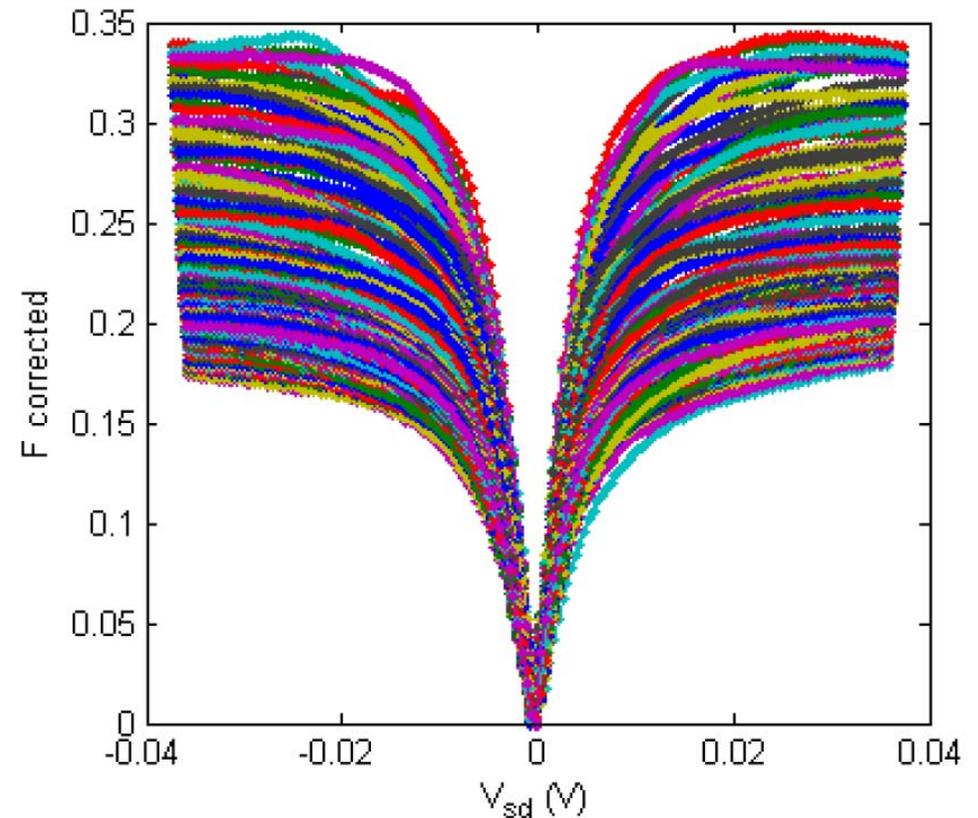
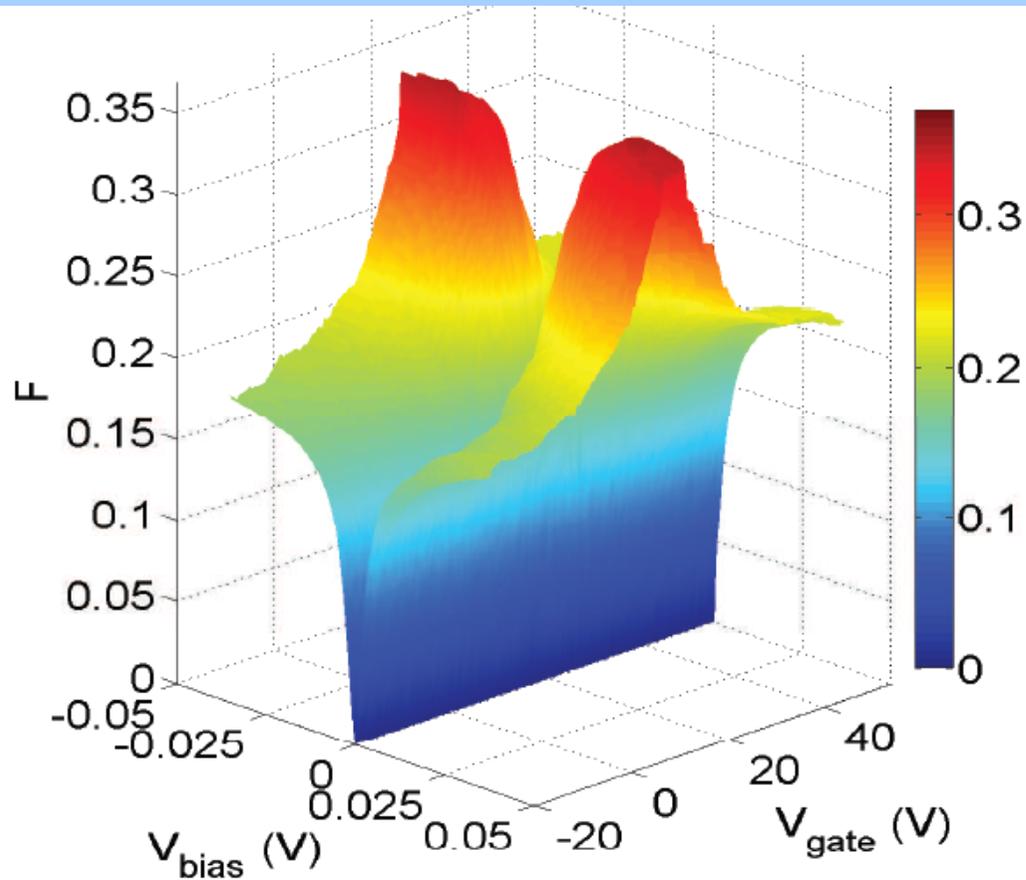
Fit yields: $F = 0.318$



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Fano factor: gate and bias dependence



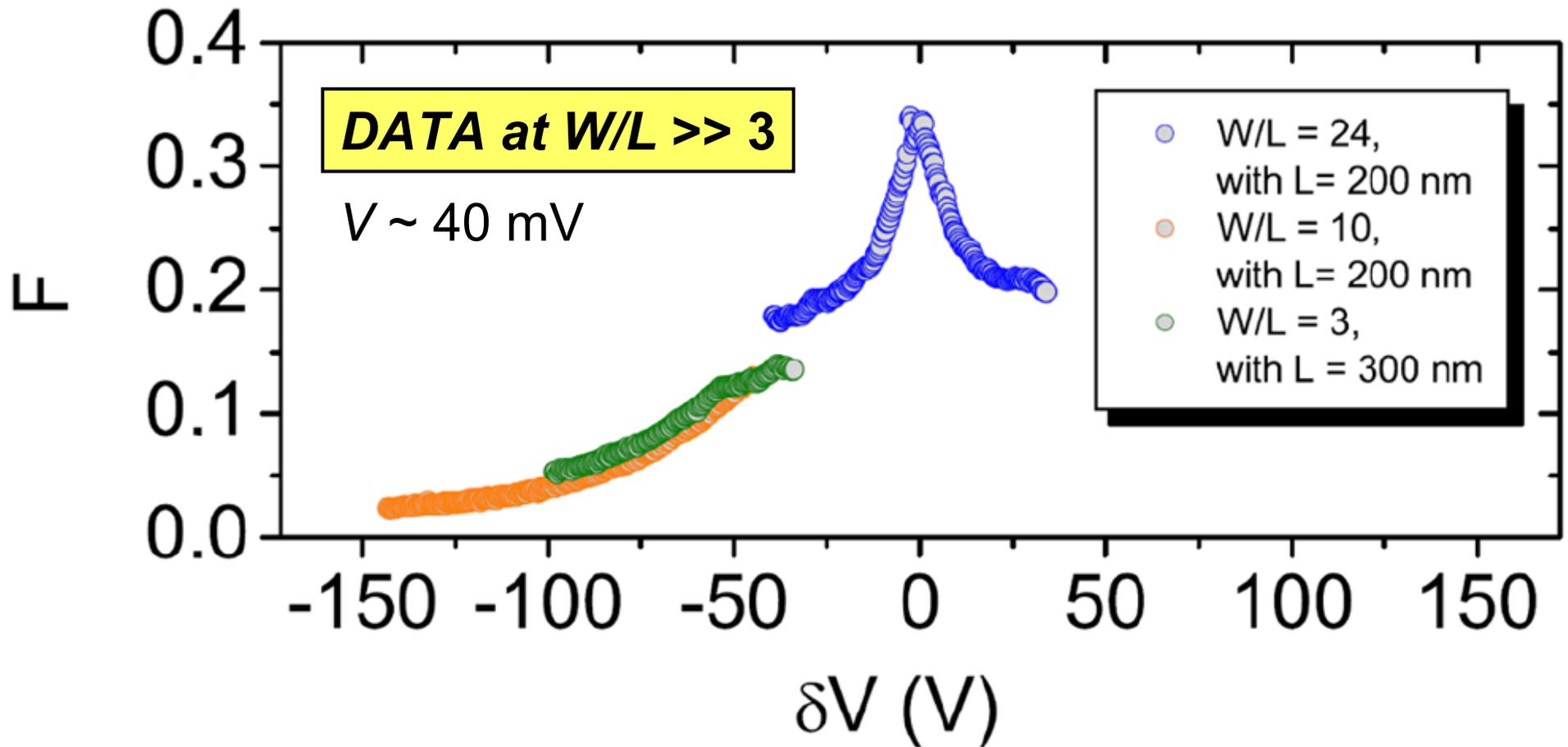
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$$F = \tilde{F} = \frac{1}{I} \int_0^I F_d dI$$

in agreement with J. Tworzydło et al.,
Phys. Rev. Lett. **96**, 246802 (2006).



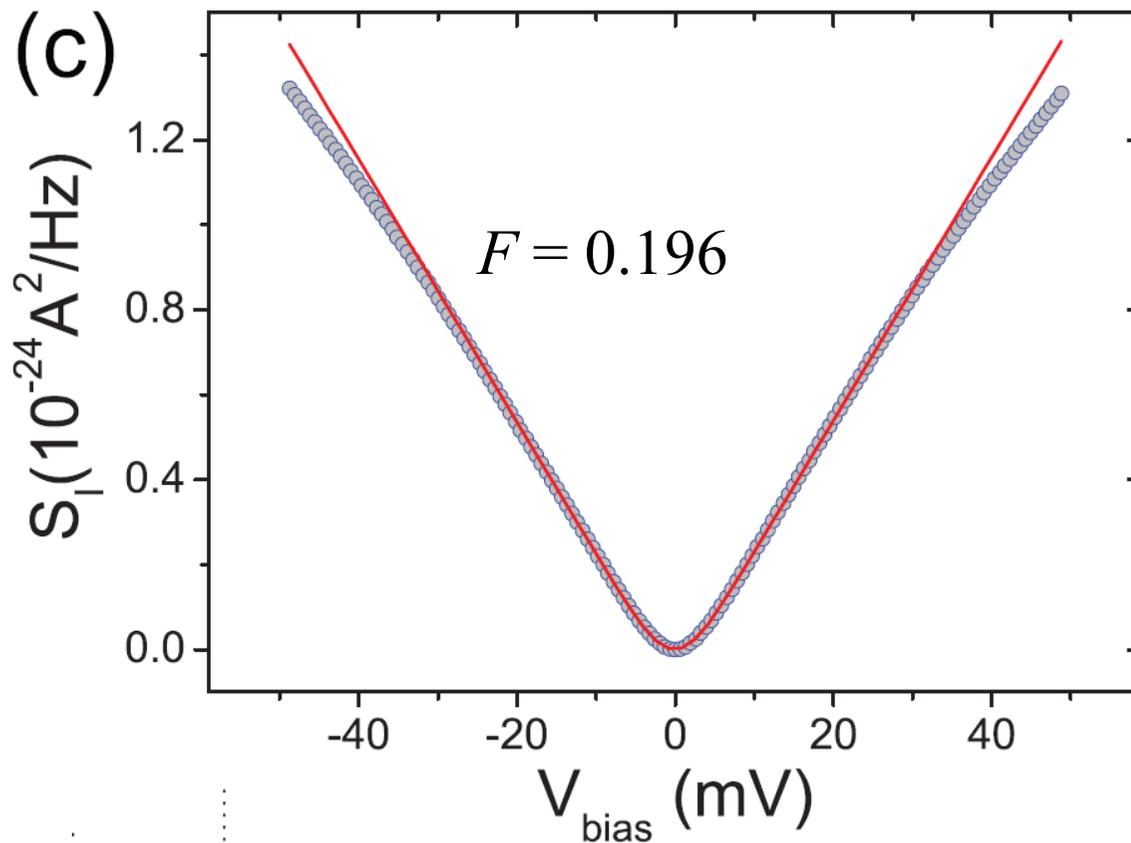
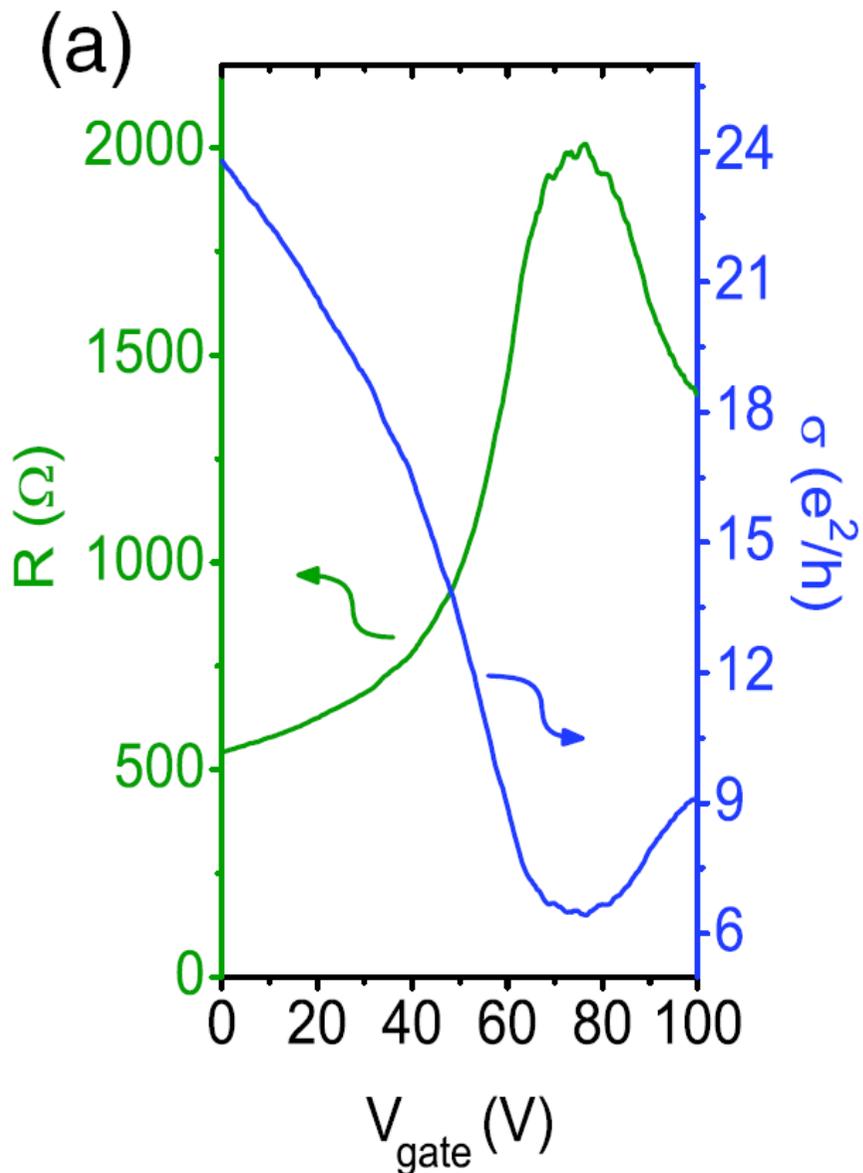
Summary of Fano factor



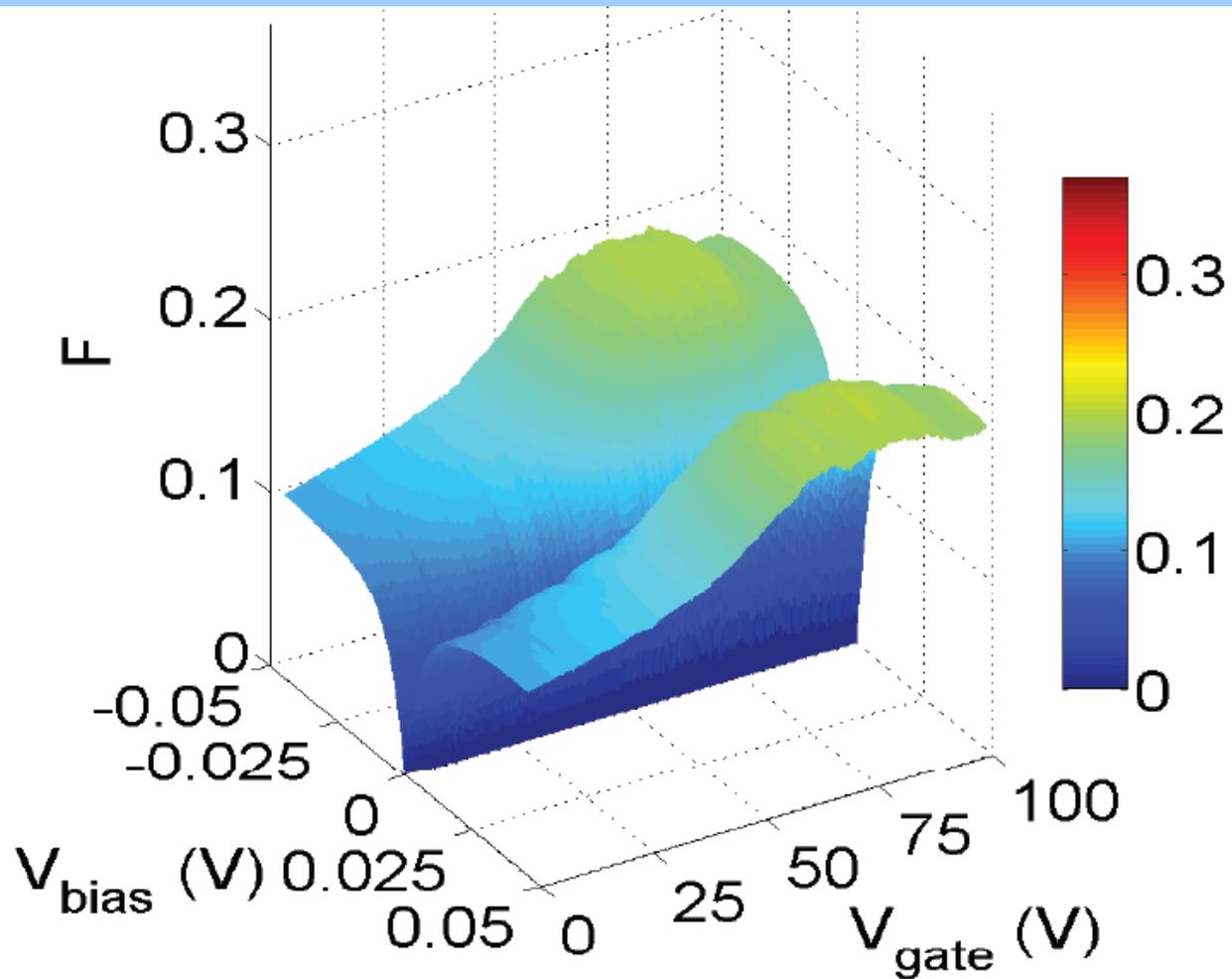
- $F = 0.338$ at the Dirac point (with $W/L \gg 3$)
- nearly ballistic at large carrier concentration



Sample with $W/L = 2$ ($L = 0.5 \mu\text{m}$)



Fano factor: sample with $W/L = 2$



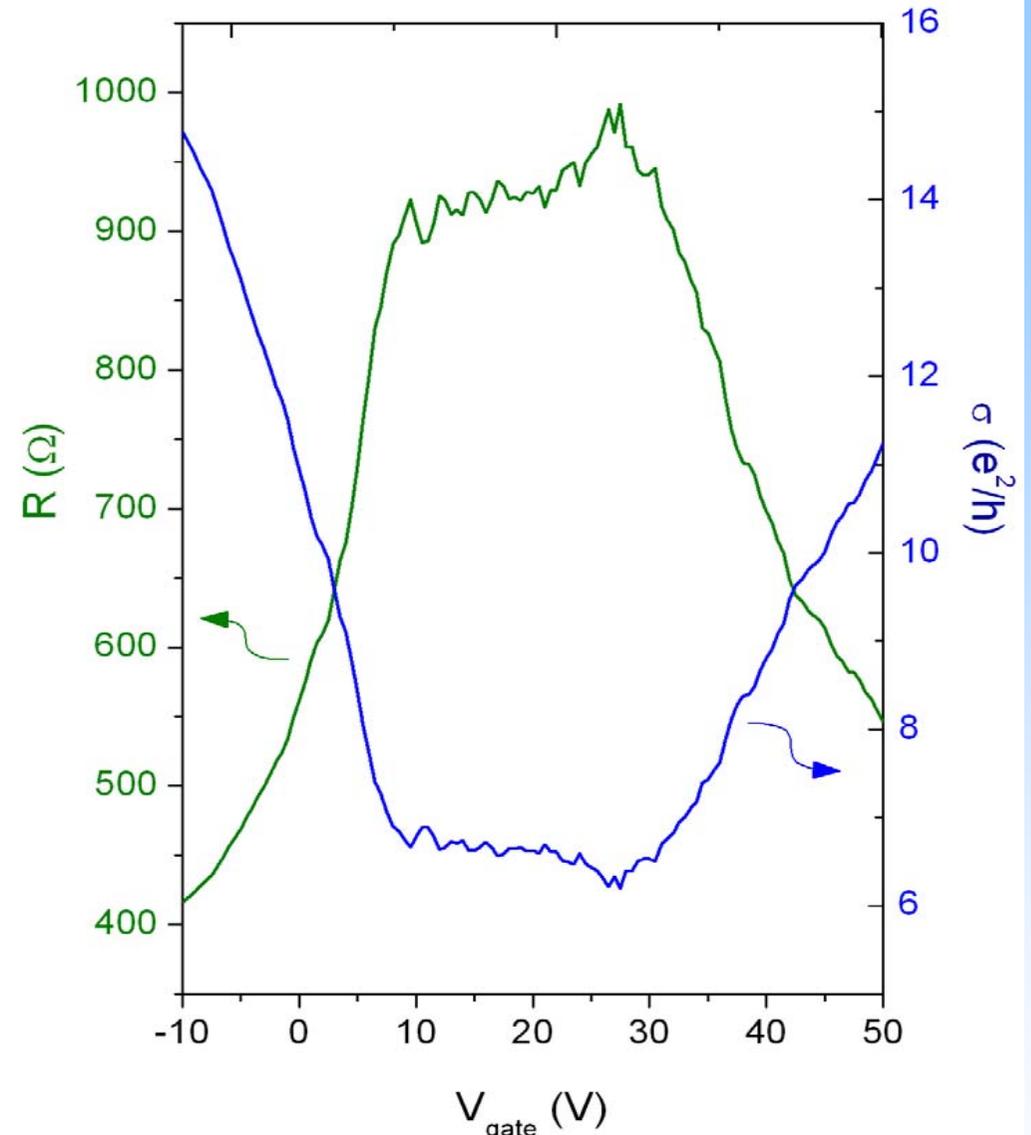
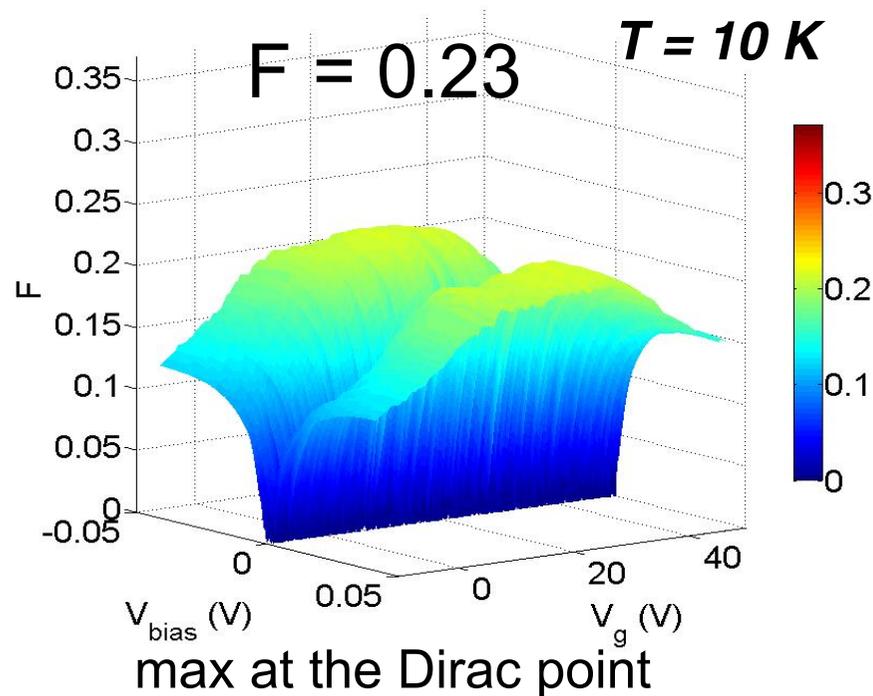
- $F = 0.19$ at the Dirac point
- Agreement with metallic armchair edge



Disorder?

- $L = 950$ nm
- $W/L = 4.2$
- $\sigma_{\min} \sim 6 G_0$

1D disorder:
 $F = 0.25$ like
chaotic cavity



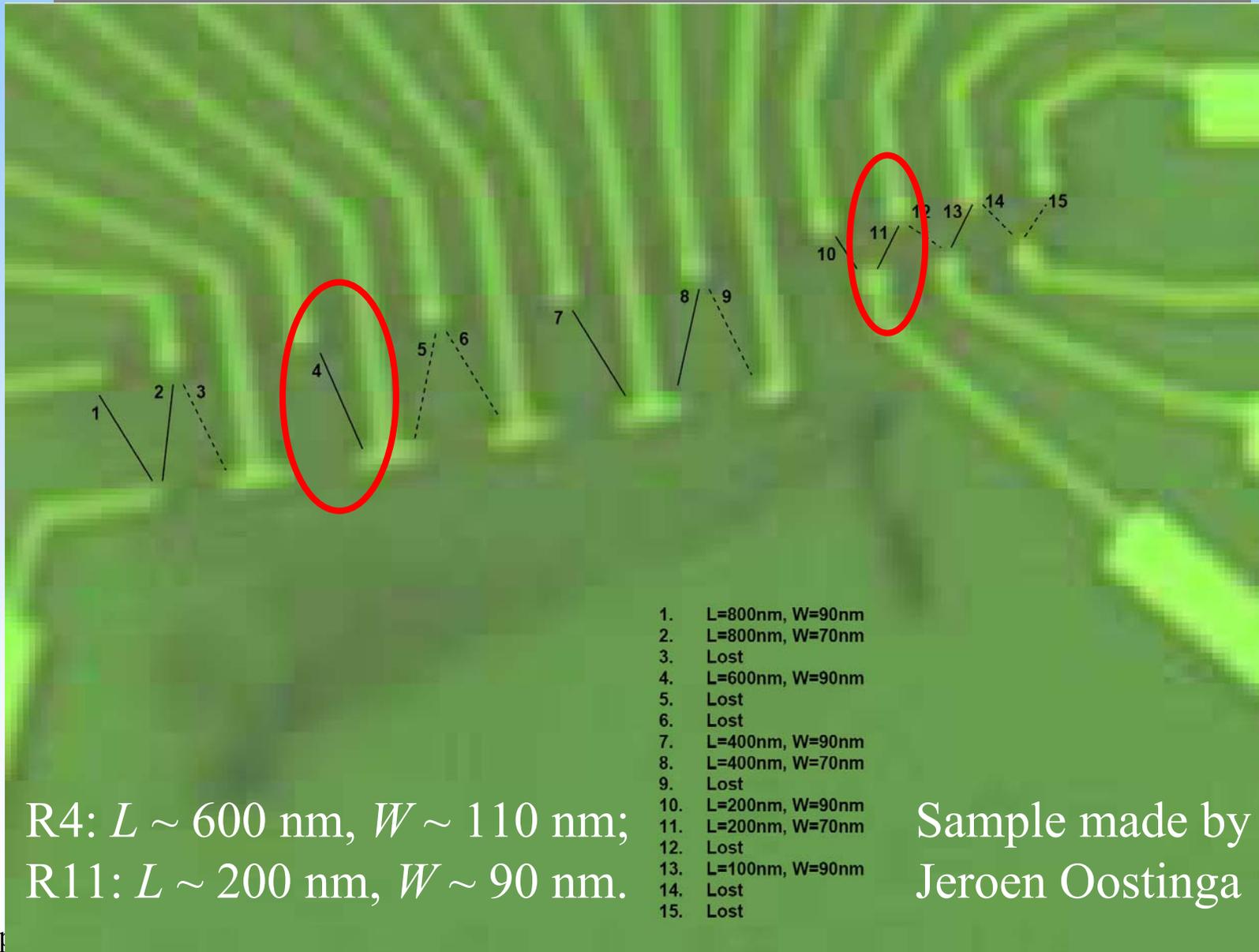
P. San-Jose, E. Prada, and D. Golubev, Phys. Rev. B 76, 195445 (2007).

C.H. Lewenkopf, E.R. Mucciolo, A.H. Castro Neto Phys. Rev. B 77, 081410R (2008).



M. Titov, EPL 79, 17004 (2007); arXiv:cond-mat/0611029v1.

Ribbons

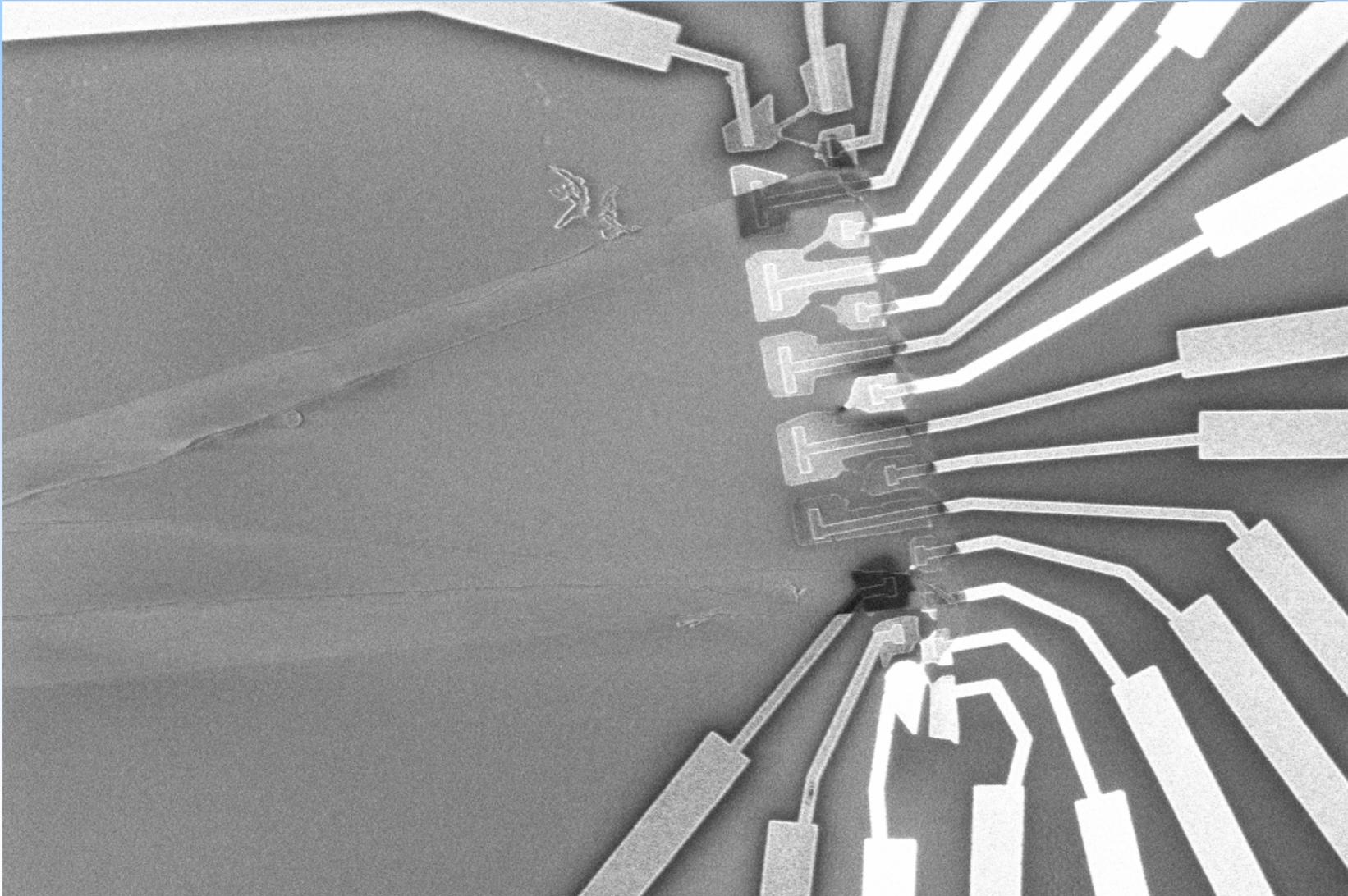


Graph
August 2008, Trieste

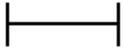
Sample made by
Jeroen Oostinga



Ribbons



2 μ m



EHT = 0.50 kV

WD = 4 mm

Signal A = InLens

Photo No. = 7519

Date :29 May 2008

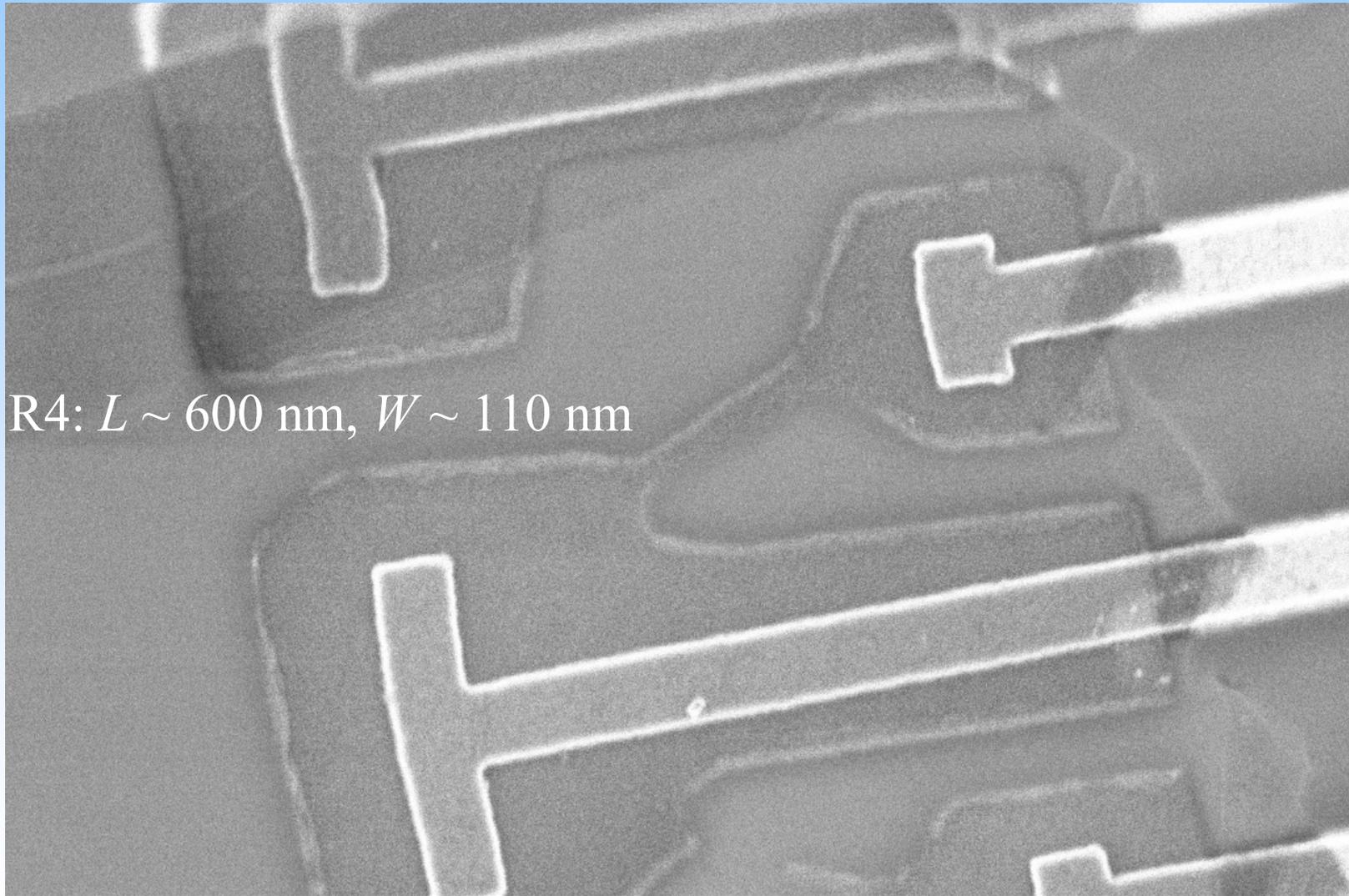
Time :16:08:44



Graph
Aug



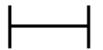
Ribbons: R4 (L ~ 600 nm, W ~ 110 nm)



R4: $L \sim 600$ nm, $W \sim 110$ nm



Graph
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200nm


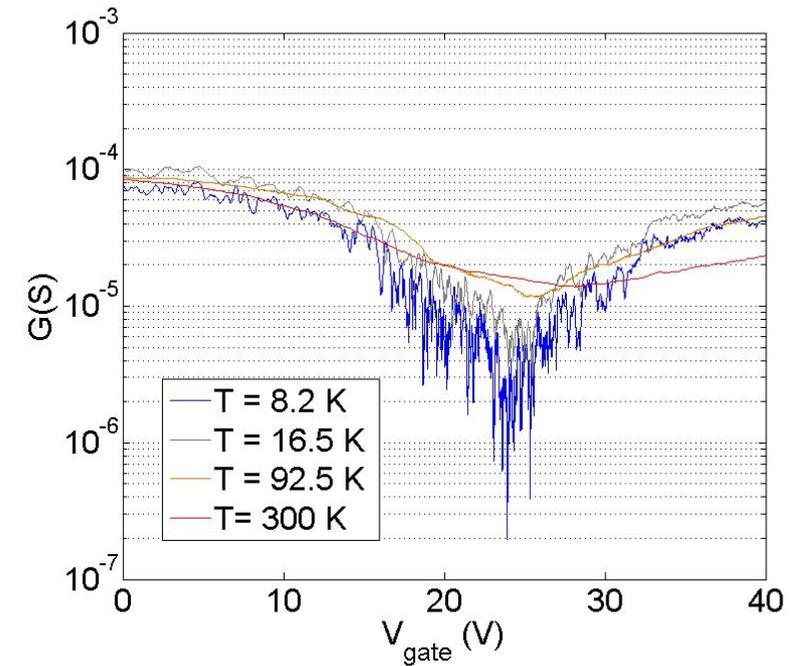
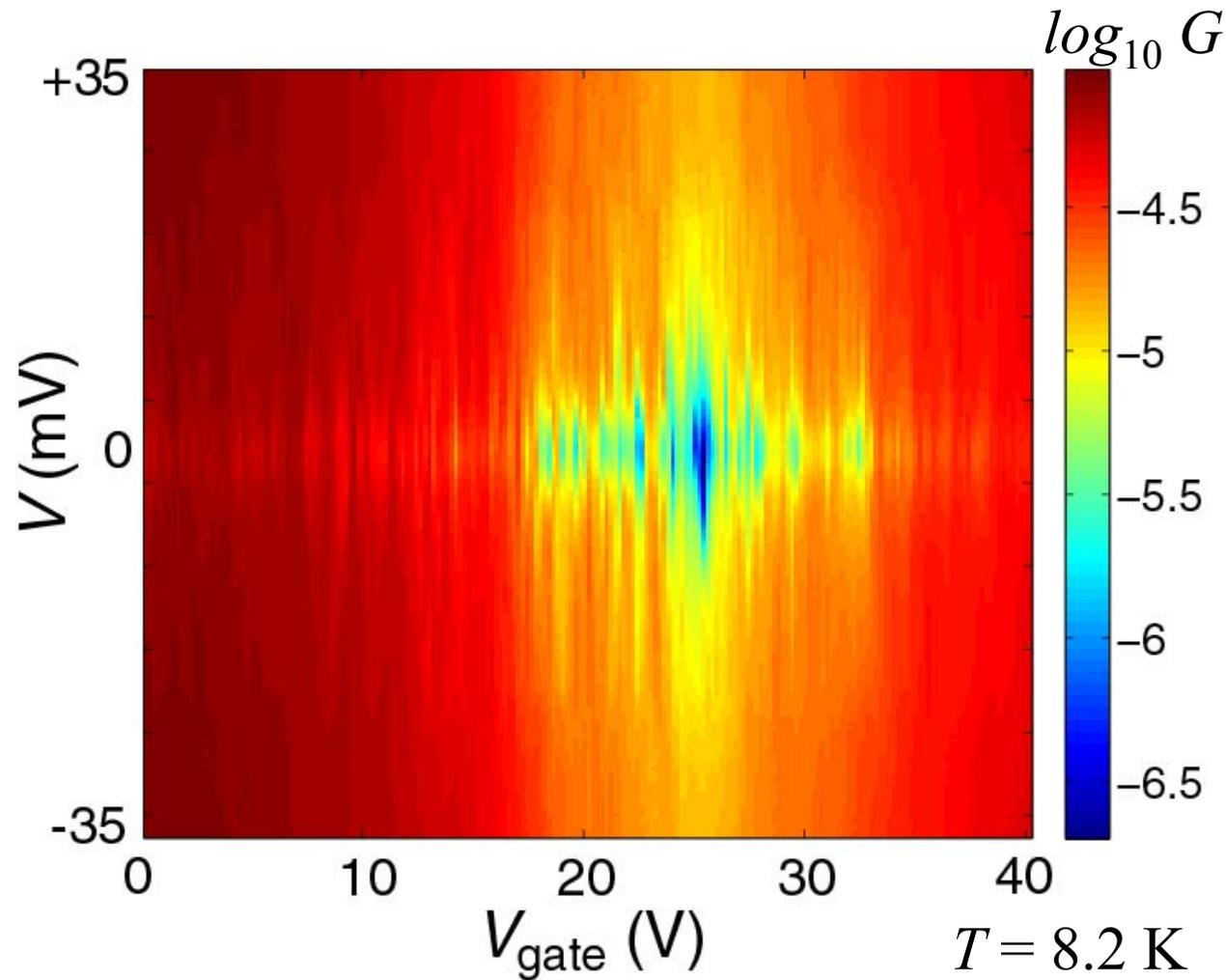
EHT = 0.50 kV
WD = 4 mm

Signal A = InLens
Photo No. = 7527

Date :29 May 2008
Time :16:19:16



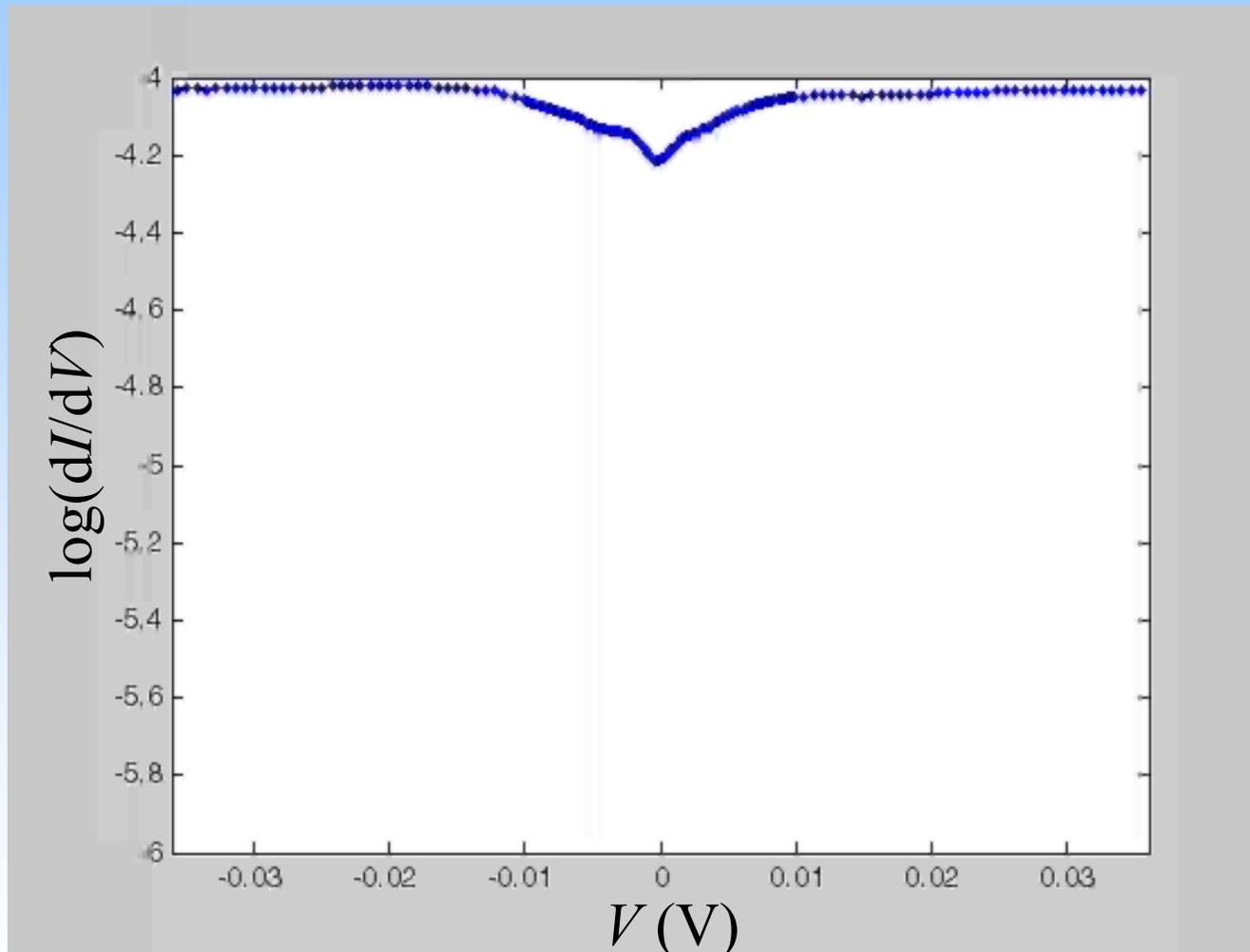
Ribbon R4 ($L \sim 600$ nm, $W \sim 110$ nm)



No gate periodicity!



Ribbon R4 ($L \sim 600$ nm, $W \sim 110$ nm)



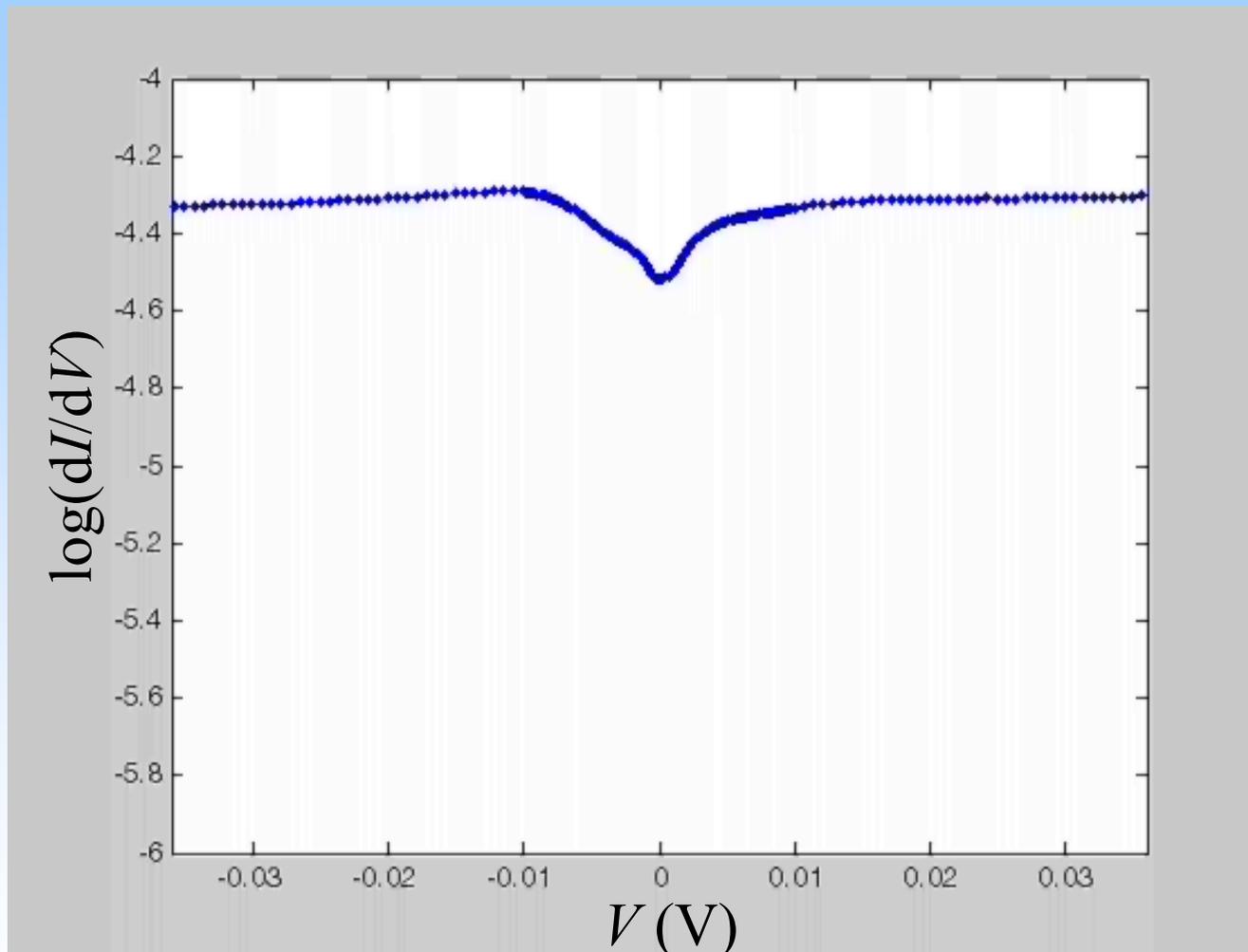
- Not simple zero bias anomaly
Conductance peaks at zero bias!?



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Ribbon R4 ($L \sim 600$ nm, $W \sim 110$ nm)



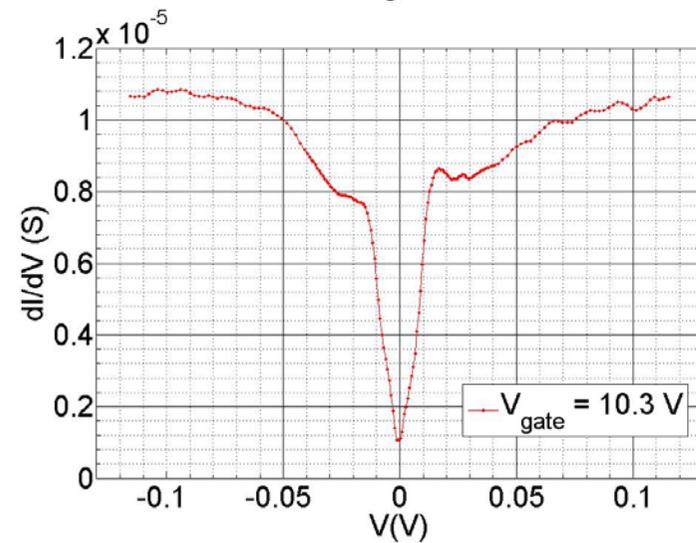
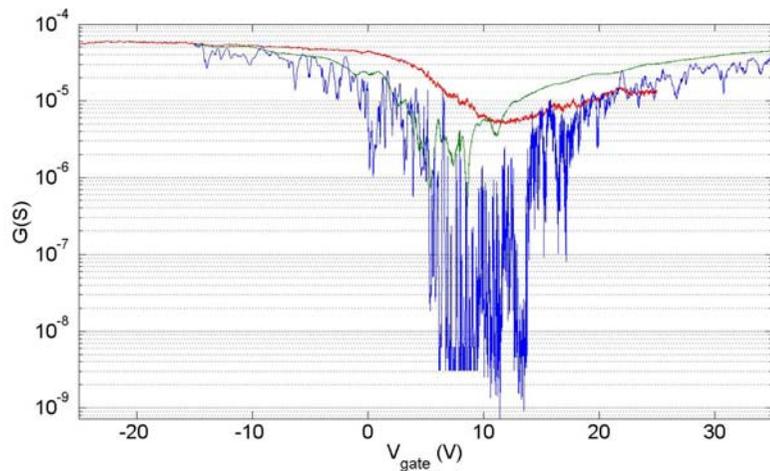
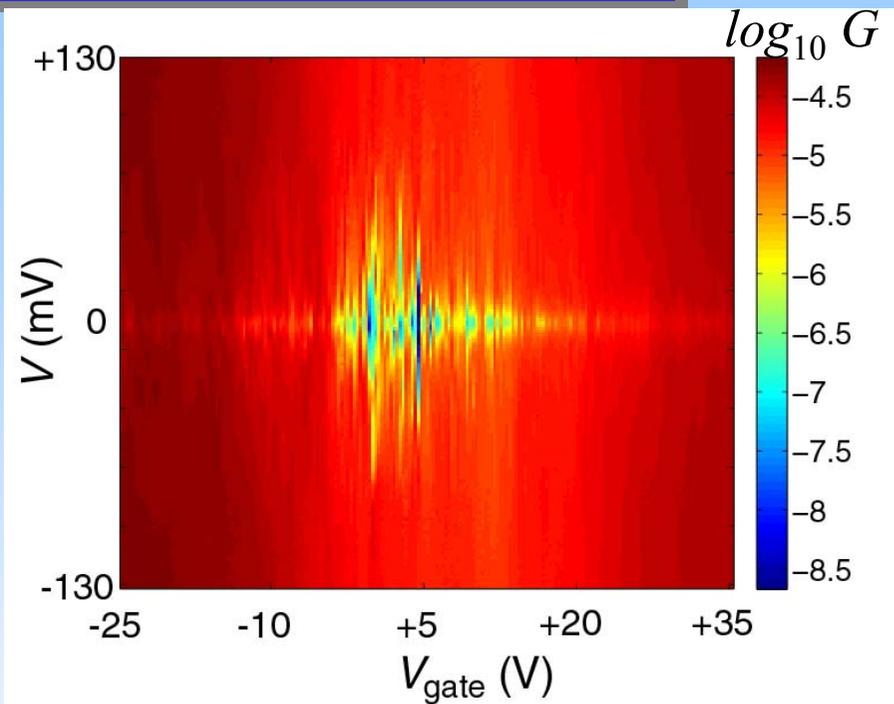
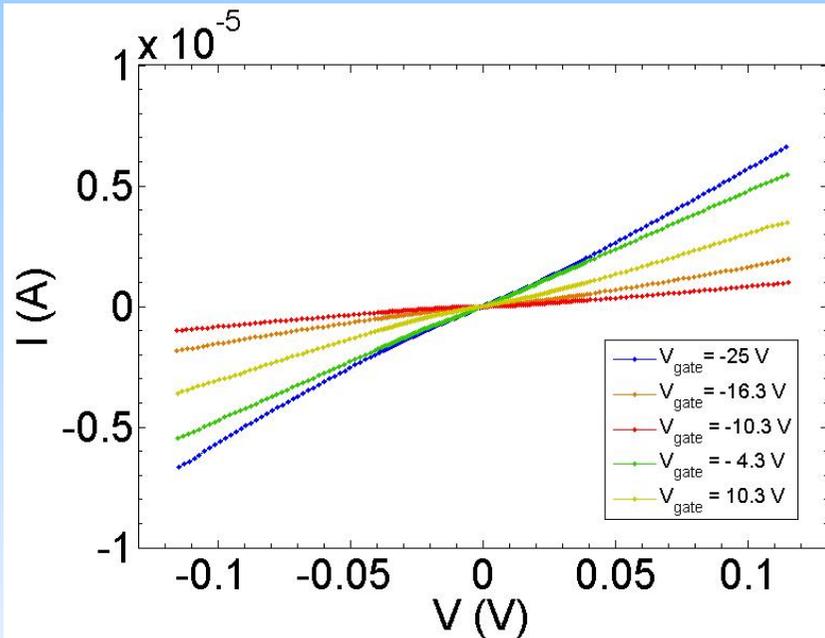
- Not simple zero bias anomaly
Conductance peaks at zero bias!?



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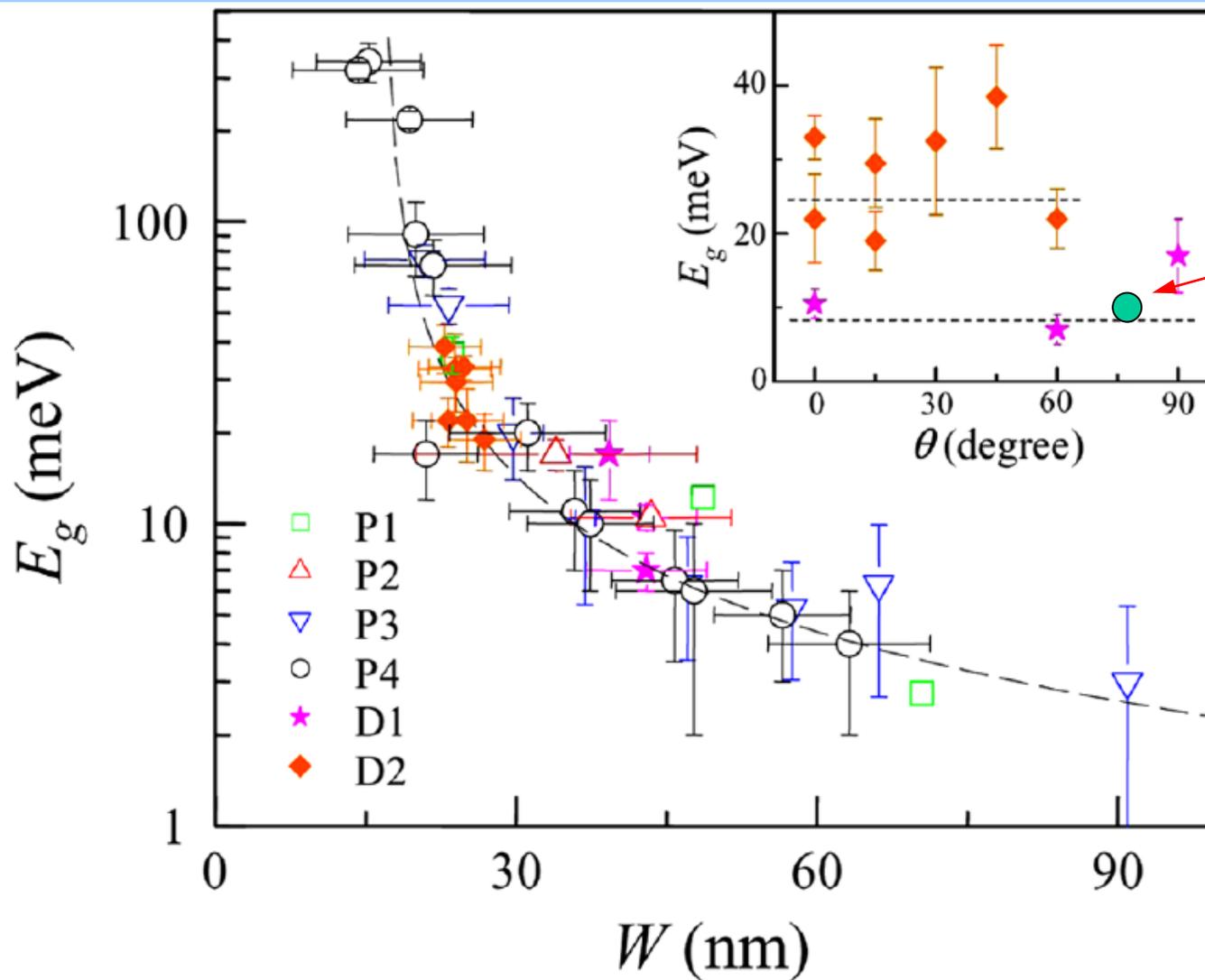
Ribbon R11 ($L \sim 200$ nm, $W \sim 90$ nm)



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Comparison of conductance gap



Our data



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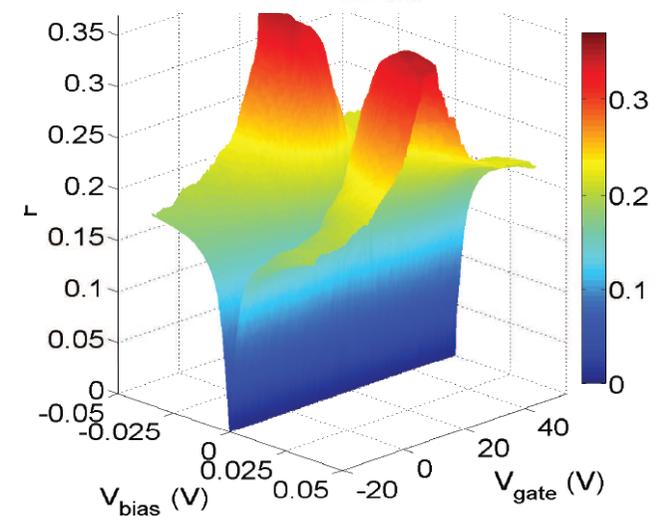
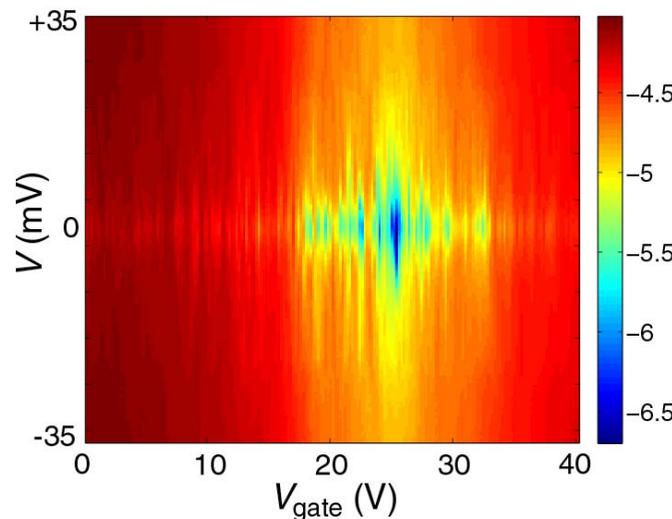
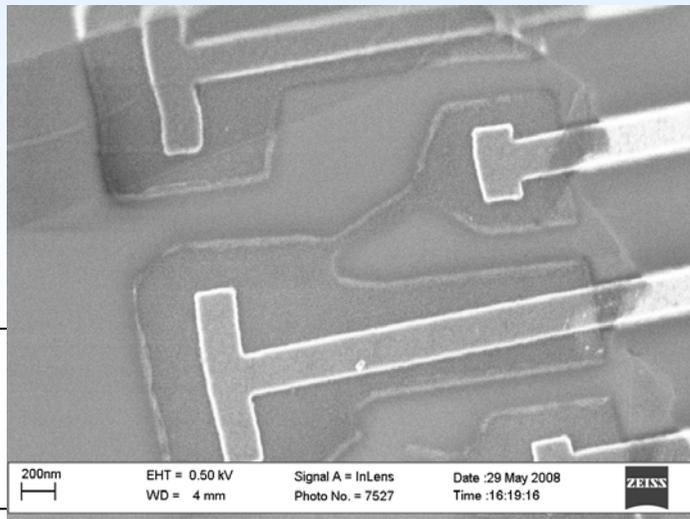
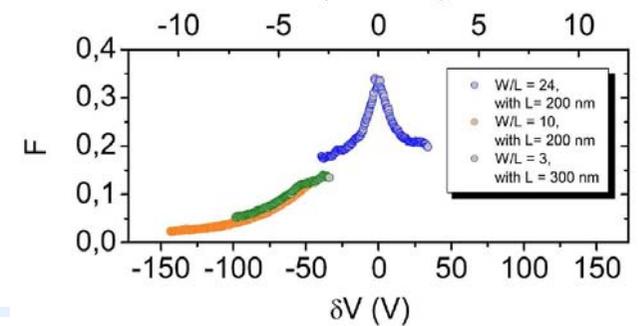
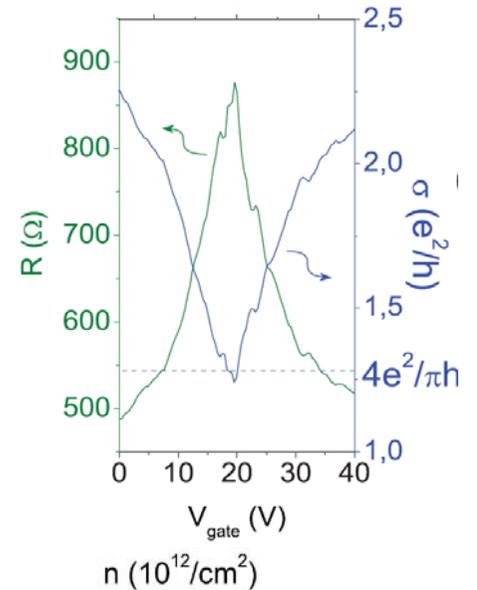
M. Y. Han, B. Özyilmaz, Y. Zhang, and P. Kim
PRL **98**, 206805 (2007).



Summary

R. Danneau, et al., Phys. Rev. Lett. **100**, 196802 (2008) + unpublished.

- $F_{\max} = 0.338$ for samples with $W/L \gg 3$
- close to predicted universal value $F_{\max} = 1/3$
- Ballistic far from Dirac point: $F_{\min} = 0.02$,
no oscillation found as a function of gate
- $F_{\max} = 0.19$ for a sample with $W/L = 2$
- Disorder effects in longer samples: $F_{\max} = 0.23$
- F small for ribbons with large "gap"
- Unknown correlations in nanoribbons?



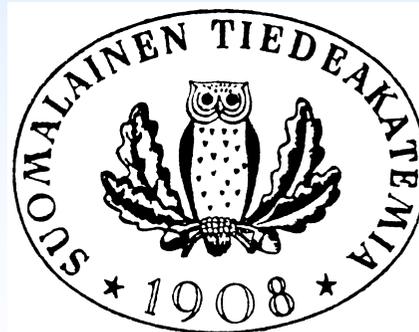
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Discussions:

*S. Haque, T. Heikkilä, M. Laakso, R. Lehtiniemi,
M. Paalanen, P. Pasanen, and P. Virtanen*



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